## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group Art Unit: 1112 Examiner: To Be Assigned

**STATUS REQUEST** 

In Re PATENT APPLICATION Of:

Applicant(s) : LIU et al.

: 08/958,460

: October 28, 1997

: HIGH DENSITY PLASMA CHEMICAL VAPOR DEPOSITION )

**PROCESS** 

**Assistant Commissioner for Patents** Washington, DC 20231

Please let us know the status of the above-identified application and when an Action may be expected.

Respectfully submitted,

Date: 8/2/1999

Steven M. Rabin (Registration No. 29,102)

RABIN & CHAMPAGNE, P.C.

1725 K Street, N.W. Suite 1111

Washington, D.C. 20006

Telephone: Telefax:

(202) 659-1915

(202) 659-1898

TC 1700 MAIL ROOF

AUG 0 2 1999

SMR/bec

acted on 8/19/99.

**RABON SERGENT** PRIMARY EXAMINER